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Central Laser Facility Science and ЫĶ Technology Facilities Council



ASTeC

Magnetic Capture and Delivery for the EPAC EA1 Electron Beamline

A.R. Bainbridge^{1,3}, N. Bourgeois², J. Crone^{1,3}, O. Findlay², C. Hill⁴, J.K. Jones^{1,3}, B.D. Muratori^{1,3}, H.L. Owen^{1,3}, T.H. Pacey^{1,3}, B.J.A. Shepherd^{1,3}, N.R. Thompson^{1,3}, Y. Saveliev^{1,3}, D. Angal-Kalinin^{1,3}, D.R. Symes²

> 1. ASTeC, STFC Daresbury Laboratory, Sci-Tech Daresbury, Warrington WA4 4AD, UK 2. Central Laser Facility, STFC Rutherford Appleton Laboratory, Harwell Campus, UK 3. The Cockcroft Institute, Sci-Tech Daresbury, Warrington WA4 4AD, UK

Introduction

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The Extreme Photonics Applications Centre (EPAC) is a new national facility currently under construction at the Rutherford Appleton Laboratory, UK. EPAC will enable a wide variety of user experiments with a state-of-the-art petawatt-class laser system.

This will include laser wakefield acceleration of electrons to energies ranging from

100 MeV to 5 GeV or higher. EPAC is designed to be flexible, allowing users to select the relevant central electron energy for their experiment.

ASTeC/CLF have designed a beamline to:

- 1. Capture laser-plasma driven electrons with broad energy spread,
- Measure their energy spectrum,
- Perform selection of specific energies if necessary, 3.
- 4. Deliver these electrons to a user interaction point.

Facilities based on LWFA technology are still in their early stages. We expect high-divergence electron bunches to be produced with significant energy spreads as much as 10%, accompanied by a long low-energy "tail". Energy spreads as small as 1% should be achievable after sufficient beam commissioning, in-line with other facilities.

Motorised	
screen	Full system

4. Technology Department, STFC Daresbury Laboratory, Sci-Tech Daresbury, Warrington WA4 4AD, UK



Beam Direction



